

<b>FORM 1449*</b> <b>INFORMATION DISCLOSURE STATEMENT</b> <b>IN AN APPLICATION</b> (Use several sheets if necessary)		<b>NOV. 22 2006</b> 	Docket Number: 10873.1440US01	Application Number: 10/809,033
			Applicant: SASAKI, et al.	Filing Date: March 25, 2004

## U.S. PATENT DOCUMENTS

## FOREIGN PATENT DOCUMENTS

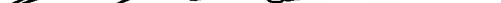
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
<i>GNR</i>	63-188938	August, 1988	Japan			Abstract	
	0 497 350	August, 1992	EPO				
	4-297023	October, 1992	Japan			Abstract	
	95/04845	February, 1995	WIPO				
	2000-233993	August, 2000	Japan			Abstract	
<i>V</i>	2002-184701	June, 2002	Japan			Abstract	
<i>V</i>	2004-006568	January, 2004	Japan				

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

		Karpov, et al., "Effect of Reactive Ambient on AlN Sublimation Growth", Phys. Stat. Sol. (a) 188, No. 2, 763-767 (2001)

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EXAMINER  DATE CONSIDERED 12/22/06

**EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.